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(54) Title: ADDITIVE MANUFACTURING TECHNOLOGY (AMT) LOW PROFILE RADIATOR

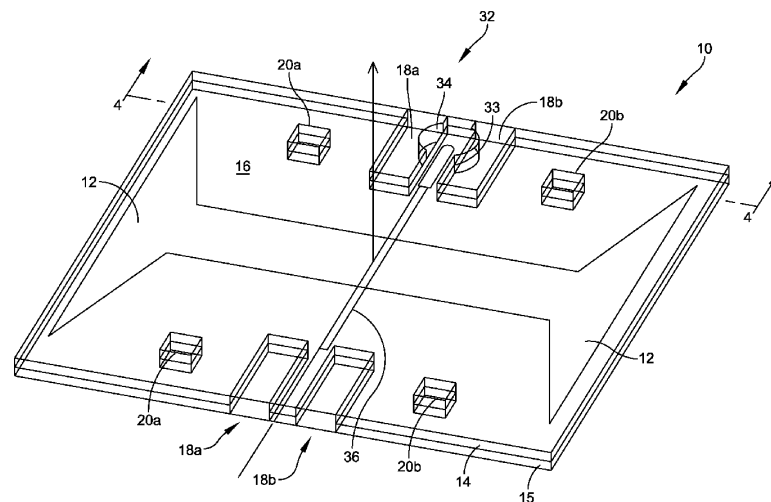


FIG. 3

(57) Abstract: Described herein is a low profile radiator (LPR) manufactured using additive manufacturing technology (AMT). Such an AMT radiator is suitable for use in an array antenna which may be fabricated using AMT manufacturing processes.

[Continued on next page]

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